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TECHNOLOGY CENTER 2800

PATENT APPLICATION

**RESPONSE UNDER 37 CFR §1.116
EXPEDITED PROCEDURE
TECHNOLOGY CENTER ART UNIT 2851**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Reissue Application of

Osamu TANITSU et al.

Group Art Unit: 2851

Application No.: 09/326,214

Examiner: A. Mathews

Filed: June 3, 1999

Docket No.: 103512.99

For: **ILLUMINATION OPTICAL APPARATUS AND SCANNING EXPOSURE
APPARATUS**

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JJP

AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

In reply to the September 16, 2002 Office Action, the shortened statutory period for reply being extended by the attached Petition for Extension of Time, please amend the above-identified application as follows:

Please replace claims 43, 54, 64, 76-78 and 80 with the following amended claims:

43. (Amended) A scanning exposure apparatus comprising:

an illumination optical system, an optical axis of said illumination optical system being substantially perpendicular to a rectangular area on a predetermined plane on which a mask is arranged, said illumination optical system comprising an internal reflection type integrator with an exit plane having a shape substantially equal to that of said rectangular area on said predetermined plane, and said illumination optical system illuminating said rectangular area with an illumination beam; and